



FORM 280-1449 MODIFIED				Docket No.: 2950.20US01		Application No.: 09/845,985	
INFORMATION DISCLOSURE CITATION IN AN APPLICATION				APPLICANT: CHALONER-GILL et al.			
				FILING DATE: April 30, 2001			
				GROUP ART UNIT: 1755			
U.S. PATENT DOCUMENTS							
EXAMINE R INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
M	4,842,832	06/1989	Inoue et al.	/	/	<div style="text-align: center;">RECEIVED FEB 20 2002 TC 1700</div>	
/	5,162,267	11/1992	Smyth				
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FOREIGN PATENT DOCUMENTS							
EXAMINE R INITIAL	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO	
M	WO 99/23191	05/1999	PCT	/	/	/	/
/	WO 00/27754	05/2000	PCT				
/	WO 00/54291	09/2000	PCT				
M	WO 01/99215 A1	12/2001	PCT				
OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)							
M	Andersson et al., "Thermal Stability of LiFePO ₄ -Based Cathodes", Electrochemical and Solide-State Letters, 3(2):66-68, 2000						
/	Bi et al., "Coating Formation by Reactive Deposition", U.S. Patent Application No. 09/715,935, filed November 17, 2000, 99 pages (application & drawings)						
M	Brousse et al., "All oxide solid-state lithium-ion cells", J. Power Sources, 68:412-415, 1997						
M	Padhi et al., "Effect of Structure on the Fe ⁺³ /Fe ⁺² Redox Couple in Iron Phosphates", J. Electrochem. Soc., 144:1609-1613, May 1997						
EXAMINER SIGNATURE <i>Mark P. Hittly</i>				DATE CONSIDERED 4/8/03			
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							

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